

UTILITY PATENT APPLICATION TRANSMITTAL

Only for new nonprovisional applications under 37 CFR 1.53(b)

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SCHWARTZ ET AL.

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APPLICATION ELEMENTS

MPEP chapter 600 concerning utility patent application contents.

ADDRESS TO:

Assistant Commissioner for Patents
Box Patent Application
Washington, DC 202311. ☒ Fee (Authority to charge deposit account below.)
(Submit an original, and a duplicate for fee processing)2. ☒ Specification [Total Pages

- Descriptive title of the invention
- Cross References to Related Applications (if needed)
- Statement Regarding Fed sponsored R & D (if needed)
- Reference to Microfiche Appendix (if filed)
- Background of the Invention
- Brief Summary of the Invention
- Brief Description of the Drawings (if filed)
- Detailed Description
- Claim(s)
- Abstract of the Disclosure

3. ☐ Drawing(s) (35 USC 113) [Total Sheets 4. ☐ Oath or Declaration [Total Pages

- a. ☐ Newly executed (original or copy)
- b. ☐ Copy from a prior application (37 CFR 1.63(d))
(for continuation/divisional with Box 14 completed)
- i. ☐ **DELETION OF INVENTORS**
Signed Statement below at 15 deleting
inventor(s) named in the prior application,
see 37 CFR 1.63(d)(2) and 1.33(b).

5. ☐ Incorporation by Reference (useable if Box 4b is checked)
The entire disclosure of the prior application, from which a
copy of the oath or declaration is supplied under Box 4b, is
considered as being part of the disclosure of the
accompanying application and is hereby incorporated by
reference therein.6. ☐ Microfiche Computer Program (Appendix)7. Nucleotide and/or Amino Acid Sequence Submission
(if applicable, all necessary)

- a. ☐ Computer Readable Copy
- b. ☐ Paper Copy (identical to computer copy)
- c. ☐ Statement verifying identity of above copies

ACCOMPANYING APPLICATION PARTS

8. ☐ Power of Attorney9. ☐ Information Disclosure Statement (IDS)/Cover ☐ Copies of IDS Citations
Letter plus PTO-144910. ☐ Preliminary Amendment11. ☒ Return Receipt Postcard (MPEP 503)
(Should be specifically itemized)12. ☐ Certified Copy of Priority Document(s)
(if foreign priority is claimed)13. ☐ Other:

14. If a CONTINUING APPLICATION, check appropriate box and supply the requisite information:

☐ Continuation ☐ Divisional ☐ Continuation-in-part (CIP) of prior Application No.: ____/____15. ☐ **DELETION OF INVENTOR(S) STATEMENT:** This application is being filed by less than all the inventors named in the prior
application. In accordance with 37 CFR 1.63(d)(2) and 1.33(b), the Assistant Commissioner is requested to delete the name(s) of
the following person or persons who are not inventors of the invention being claimed in this application:16. ☐ Amend the specification by inserting before the first line the sentence:-- This is a ☐ continuation-in-part, ☐ continuation, ☐ division of Application No. _____ filed
, now abandoned. --17. ☐ Cancel in this application original claims ____ of the prior application before calculating the filing. (At least one
original independent claim must be retained for filing purposes.)18. ☐ Priority of foreign Application No. _____ filed on _____ in_____ is claimed under 35 U.S.C. 119.
(country)

CLAIMS	(1) FOR	(2) NUMBER FILED	(3) NUMBER EXTRA	(4) RATE	(5) CALCULATIONS
	TOTAL CLAIMS (37 CFR 1.16(c))	1 - 20 =	0	x \$ 18 =	0
	INDEPENDENT CLAIMS (37 CFR 1.16(b))	1 - 3 =	0	x \$ 78 =	0
	MULTIPLE DEPENDENT CLAIM(S) (if applicable)			+ \$ 260 =	0
				BASIC FEE (37 CFR 1.16(a))	+ \$ 690.00
				TOTAL =	\$ 690.00

19. The Commissioner is hereby authorized to credit overpayments or charge the following fees to Deposit Account No. 04-1928:

a. ☒ Fees required under 37 CFR 1.16.

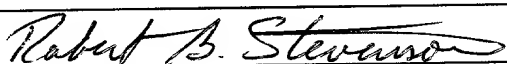
b. ☒ Fees required under 37 CFR 1.17.

20. ☐ Other:

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22. SIGNATURE OF ATTORNEY OR AGENT REQUIRED

NAME	Robert B. Stevenson	REG. NO.: 26,039
SIGNATURE		
DATE	11 July 2000	

TITLE OF THE INVENTION
PROCESS FOR MANUFACTURE OF AN
ATTRITION RESISTANT CATALYST

5 CROSS REFERENCE TO RELATED APPLICATION

Benefit of priority is being claimed from the Provisional
Application 60/143,667 filed July 14, 1999.

BACKGROUND OF THE INVENTION

10 1. Field of the invention:

This invention relates a process for preparing an attrition resistant catalyst. More specifically, but not by way of limitation, the invention relates to a method of imparting attrition resistance to a particulate catalyst or catalyst precursor (e.g., vanadium/phosphorus oxide, V/P/O, solids) by spray drying a
15 slurry containing catalyst or catalyst precursor and optionally a large size silica colloidal sol, polysilicic acid or mixtures thereof in the presence of H_3PO_4 followed by calcining the spray dried product.

2. Description of the Related Art:

The use of inert metal oxides such as silica or the like as a support for
20 catalysts or as a binder for catalyst particles is generally well known in the art. In particular, U.S. Pat. No. 4,677,084 discloses and claims a process for producing attrition resistant catalyst or catalyst support particles having an oxide-rich surface layer as well as claims the attrition resistant particles. In a
divisional U.S. Pat No. 4,769,477 the use of attrition resistant
25 vanadium/phosphorus oxide catalyst particles (made by the above process) having a SiO_2 -rich surface layer for producing maleic anhydride by oxidation of a hydrocarbon is similarly disclosed and claimed. The method of producing the attrition resistant catalyst particles according to these patents involves the forming of a slurry of catalyst, catalyst precursor or catalyst support particles in
30 a solution containing a solute consisting essentially of the oxide precursor

particle (i.e., that which becomes or forms the resulting oxide-rich surface layer; e.g., silicic acid, polysilicic acid or the like). This oxide precursor particle useful in this process is characterized by an average particle size no greater than 5 nanometers and the relative amount of the same is chosen such that the weight of the oxide to be formed as a surface layer is about 3 to 15 percent of the total weight of the resulting attrition resistant particles. This slurry is then spray dried to form porous microspheres which are then calcined to produce attrition resistant catalyst. Both of these patents further contain extensive background reviews of relevant prior patent references and the present invention can be viewed as a further improvement relative to each. As such, U.S. Pat. Nos. 4,677,084 and 4,769,477 are incorporated herein by reference for disclosure purposes.

U. S. Pat. No. 5,302,566 discloses an alternate method for preparing an attrition resistant catalyst described above, particularly vanadium/phosphorus oxide catalyst, having an oxide-rich surface layer. In this alternative method the slurry to be spray dried comprises the catalyst or catalyst precursor particles and a mixture of a solution containing a solute consisting essentially of the oxide precursor particles of less than 5 nm along with a colloidal oxide sol wherein the oxide sol particles have an average size of between 5 and 7 nm. The amount of colloidal oxide sol is selected such as to provide between 50 to 95 percent by weight of the final oxide-rich surface and the polysilicic acid provides 5 to 5 percent. Again, the oxide-rich surface is between 3 and 15 percent by weight of the total weight of resulting attrition resistant catalyst. The resulting catalyst made by this alternative process is shown to be comparable in attrition resistance properties to a catalyst made using only oxide precursor solution as the surface forming oxide source. The mixture of combined oxide precursor solution and 5 to 7 nm colloidal sol, however, is significantly more stable than a solution of oxide precursor alone. Consequently, advantages in terms of shelf-life, storage, and handling are

realized particularly when scaling up to commercial production levels. U. S. Pat. No. 5,302,566 is incorporated herein by reference for disclosure purposes.

In a copending and commonly assigned U.S. Pat. application 09/163,680 filed September 30, 1998, incorporated herein by reference, a further improvement relating to the above described processes is disclosed. In this process the colloidal oxide sol employed has an average size between 10 and 100 nm and the amount used is selected such that from 25 to 50 percent of the resulting weight of attrition resistant catalyst is derived from the colloidal oxide sol. The soluble solute component (e.g., the silicic acid or polysilicic acid) in the slurry prior to spray drying again is characterized by an average particle size no greater than 5 nm and the amount employed is selected such that from 5 to 15 percent of the weight of the attrition resistant catalyst (including the colloidal sol contribution) is derived from the soluble oxide precursor. This particular process and resulting attrition resistant catalyst is intended to alleviate a specific problem associated with transition metal oxide containing catalysts that can expand and shrink during the oxidation and reduction cycles associated with continuous use and the associated increase attrition losses observed during the reduced state.

BRIEF SUMMARY OF THE INVENTION

In view of the above prior art, it has now been discovered that an attrition resistant vanadium/phosphorous oxide catalyst can be prepared by intentionally employing phosphoric acid, H_3PO_4 , or the like in the aqueous slurry containing vanadium/phosphorous oxide catalyst or catalyst precursor particles to be spray dried. Optionally a large size silica colloidal sol, polysilicic acid or mixtures thereof may be advantageously present in the aqueous slurry prior to spray drying in the presence of H_3PO_4 . The spray dried solids are then calcined and activated as generally known in the art.

Thus the present invention provides a process for manufacture of an attrition resistant vanadium/phosphorous oxide catalyst comprising the steps of:

a) forming a slurry comprising;

- i) vanadium/phosphorous oxide catalyst or vanadium/
phosphorous oxide catalyst precursor particles,
- ii) aqueous H_3PO_4 solution, and
- iii) optionally an aqueous colloidal silica sol, an aqueous
polysilicic acid solution or mixture thereof;

b) spray drying the slurry from step (a) to form attrition resistant catalyst
precursor solids; and

c) calcining the spray dried solids of step (b) to produce attrition
resistant catalyst.

DETAILED DESCRIPTION OF THE INVENTION

The process of the present invention is technologically related to the
process described in U.S. Pat. Nos. 4,677,084; 4,769,477 and 5,302,566 and
consequently the full disclosure of each is incorporated herein by reference for
disclosure purposes. The process of the present invention is also
technologically related to the process described in co-pending and commonly
assigned U.S. Provisional Pat. Application No. 60/109403 filed November 20,
1998 and consequently the full disclosure of this provisional application is
incorporated herein by reference for disclosure purposes. As set forth in the
above three published patents, the small particle size of the oxide precursor in
solution (i.e., no greater than 5 nm) is important during the spray drying of the
slurry in that it enables the oxide precursor to flow to the peripheral region of
the porous microsphere being formed. The small particle size is also identified
as being important in producing the hard peripheral oxide-rich outer shell or
surface layer responsible for the attrition resistance. As described in the
4,677,084 and 4,769,477 issued to Bergna, when this oxide precursor is an
aqueous silicic acid or polysilicic acid solution of particle size no greater than 5
nm which is spray dried at for example 10 weight percent SiO_2 loading with a
vanadium/phosphorus oxide catalyst precursor and then calcined at typically
400°C for 1 hour an attrition resistant porous microsphere will be achieved.
These three references further teach that the particles of silica 2 to 6 nm in

diameter sinter together to some extent even under the temperature conditions encountered in a conventional spray drying process, whereas particles 10 to 100 nm do not sinter below 700 to 1,000°C. As a result, attrition resistance of the catalyst, catalyst precursor or support particle is a function of the particle
5 size and degree of aggregation of the silica formed by dehydration during spray drying.

In view of the fact that particles of silica 2 to 3 nm in diameter, such as those present in polysilicic acid solution, form hard shells on the resulting porous microspheres under conventional spray drying conditions, the 4,677,084
10 and 4,769,477 patents acknowledge and define the concept of "green" attrition resistant; i.e., the attrition resistance before calcination of the porous microsphere. It is further taught that the green attrition resistance before calcination of a vanadium/phosphorus oxide catalyst precursor with 10 weight percent SiO₂ shell prepared by using polysilicic acid is as high as the attrition
15 resistance of these microspheres after calcination at 400°C for 1 hour. These references further note that calcination of the vanadium/phosphorus oxide precursor microspheres is necessary to convert the precursor to the catalyst and, since the green attrition resistance is so high, calcination can be carried out when convenient, for example, when the microspheres are in the reactor. It is
20 further indicated that the green attrition resistance of the porous microspheres of vanadium/phosphorus oxide catalyst precursor with 10 wt% SiO₂ shell is significantly lower when a colloidal sol of particles of 5 nm is used as the source of the silica instead of polysilicic acid. Also, when a colloidal sol of particles of 14 nm diameter is used as the source of the silica, the green attrition
25 resistance is even lower. When a colloidal sol of particles of 22 nm diameter is used as the source of the silica, significant green attrition resistance is not realized even when the amount of silica is increased to 20 wt%. Furthermore, calcination of the porous microspheres of vanadium/phosphorus oxide catalyst precursor with 10 wt% SiO₂ does not result in adequate attrition resistance
30 when the silica particle diameter in the silica source exceeds 5 nm.

In U.S. Pat. No. 5,302,566 an alternate process for preparing an attrition resistant catalyst similar to the process of the 4,677,084 and 4,769,477 patents is disclosed. In this improvement the vanadium/phosphorus oxide catalyst having an SiO_2 surface layer is obtained from a stable silica forming mixture which contains both a colloidal silica sol and a soluble silica forming precursor solution. More specifically, the improved process involves the use of a colloidal oxide sol containing particles of average diameter of 5 to 7 nm in combination with the soluble silica precursor such as silicic acid or polysilicic acid. Again, a mixture of the silica forming agents are slurried with the catalyst or catalyst precursor particles and then the slurry is spray dried followed by calcination. The total oxide layer derived from the mixture of colloidal sol and polysilicic acid in the final catalyst is from 3 to 15 wt% of the attrition resistant catalyst.

The 5,302,566 patent teaches that up to 95% by weight of this oxide-rich surface may be derived from the colloidal sol and as little as 5% by weight from the polysilicic acid solution (i.e., the soluble silica). This reference again establishes that a catalyst wherein the oxide layer is derived entirely from colloidal silica (e.g. Ludox[®] FM; average particle size 5nm) exhibits unsatisfactory attrition resistance. However, a catalyst wherein the oxide is derived from both colloidal silica and very little soluble silica exhibits a very desirable level of attrition resistance fully comparable to the attrition resistance associated with a catalyst prepared using entirely soluble silica. It was found that replacing 50 to 90 % of the soluble silica (PSA) with colloidal silica results in formation of an essentially equivalent oxide shell which forms as the spray-dried droplets form the microspheres, provided the size of the particles in the colloidal sol is not greater than about 7 nm. The morphology of the resulting attrition resistant catalyst; i.e., the oxide being deposited as an outer shell, is similar to catalyst produced using soluble silica as the sole source of oxide.

The improvement associated with the 5,302,566 patent is related to the fact that the mixture containing colloidal sol and oxide precursor (PSA)

solution is considerably more stable than the oxide precursor solution alone, which as noted in this patent, tends to rapidly gel. The stability of colloidal sol/PSA mixtures combined at different proportions ranging from 50/50 wt% to 95 wt% colloidal sol and 5 wt% PSA was assessed after storage for various time periods and was found to be comparable to that of freshly prepared PSA solutions. More specifically, a 95/5 w/w mixture of Ludox[®] FM/PSA, after 5 days storage, showed a viscosity profile very similar to that of a freshly prepared solution of 5% by weight PSA (stored 30 minutes), whereas the PSA solution gelled and was intractable after 22 hours of storage. Mixtures of Ludox[®] FM/PSA prepared at 70/30 and 50/50 proportions by weight, without added precursor particles, underwent no significant change in viscosity profile following storage for 71 hours. Thus the improvement addressed in the 5,302,566 patent dealt exclusively with an observed increase in stability of the mixtures of a 5 to 7 nm colloidal sol and polysilicic acid solution and the resulting distinct processing advantages relative to the use of a PSA solution alone, particularly when the respective processes are carried out on a large commercial scale.

In contrast to the processes disclosed in these previously published patents, the process of the above cited provisional application 60/109403 involves the use of a colloidal sol wherein the average particle size is in excess of 10 nm in combination with the precursor solution of silicic acid, polysilicic acid or small diameter colloidal silica sol (less than 10 nm). In further contrast, the purpose and function of the intentional use of a colloidal sol of large particle dimensions (i.e., greater than 10 nm) is to improve the performance characteristics of the resulting attrition resistance catalyst relative to an attrition resistant catalyst prepared using PSA as the sole silica source. More specifically, the presence of the large diameter colloidal sol increases the resulting attrition resistant catalyst surface area, pore volume and pore size relative to an attrition resistant catalyst prepared using polysilicic acid as the sole silica source. The presence of the large particle size sol in combination

with the polysilicic acid solution results in a stable mixture and thus all of the processing advantages associated with the 5,302,566 patented process are achieved and retained. However, the quantitative level of attrition resistance achieved in the instant invention relative to these previous processes is somewhat diminished at comparable silica surface layer loading, but the respective attrition resistance achieved is still commercially significant and operationally practical. The performance level of the vanadium/ phosphorus oxide catalyst at 10 wt% SiO₂ of the instant process in the vapor phase oxidation of butane when compared to the corresponding attrition resistant catalyst made using only PSA shows about a 40% increase in yield and conversion at comparable percent selectivity relative to the production of maleic anhydride. The incorporation of the large size colloidal sol particles in the mixture forming the silica surface layer thus tends to create a more open structure with higher surface area and pore volume in the resulting attrition resistant catalyst. This, in turn, alleviates any inherent diffusion limitations and improves intraparticle diffusion of reactants and products. Thus the process of the provisional application 60/109403 leads to improved catalyst performance; albeit, at the partial expense of attrition resistance. However, it was found according to the provisional application 60/109403 that any associated loss in attrition resistance can, in part, be minimized by employing a greater relative amount of PSA when a larger sol is being employed (e.g., 50 wt% PSA with 60 to 75 nm particle size) and more modest amounts of PSA when a diameter sol closer to about 10 nm particle size is being employed (e.g., 5 wt% PSA with 1.2 nm particle size).

In contrast to the above, the process of this invention provides for the intentional use of phosphoric acid or an equivalent source of phosphoric acid in the aqueous slurry prior to the slurry being spray dried to for catalyst precursor solids. According to the present invention, it has been discovered that the presence of H₃PO₄ during spray drying enhances and/or improves attrition resistance in the ultimate calcined/activated vanadium/phosphorus oxide

catalyst being produced. This enhancement is observed in essentially all of the previously mentioned prior art catalyst preparation methods involving either a silica sol, silicic acid, polysilicic acid or combination thereof as the attrition resistant additive being combined with the vanadium/phosphorus oxide precursor solids. In fact and as demonstrated in the examples, it has now been found that the use of phosphoric acid in the slurry to be spray dried will contribute significant attrition resistance to the ultimate vanadium/phosphorus oxide catalyst even in the absence of a silica additive.

The catalyst or catalyst precursor useful in preparing the slurry to be spray dried can be any catalyst active solids suitable for vapor phase catalytic processes wherein attrition resistance is needed; for example; processes carried out in a recirculating solids reactor system, a transport bed reactor, fluidized bed reactor or even a fixed bed reactor. Similarly the catalyst support can be any particulate solids conveniently employed in a similar manner. The active ingredient in or on such catalysts, catalyst precursors and catalyst supports is typically a transition metal oxide or mixed oxide or any other oxides or mixed oxides; however, in the broadest application of the instant invention it can be any compatible agent. Of particular interest herein are vanadium, vanadium-phosphorus, multimetal molybdenum-vanadium and other vanadium-containing catalysts and the like that are conventionally known as the active catalytic ingredient for various vapor phase oxidation and ammoxidation reactions. Most particularly, the use of vanadium/phosphorus oxide catalyzed air oxidation of butane for commercial production of maleic anhydride is of primary interest. For this reason, the following disclosure and examples will focus on preparation of an attrition resistant vanadium/phosphorus oxide catalyst precursor as representing a particularly preferred embodiment, but the invention is not limited thereto, and preparation of other catalysts used in other vapor phase catalytic reactions are contemplated as being benefited from the process improvements disclosed herein.

The catalyst or catalyst precursor particles used in preparing the slurry can be made or obtained by synthesis or by comminuting larger particles. Typically the starting particles are of the order of 0.5 to about 10 μm in size and are to be reduced in size by micronization or similar size reduction process to a mean particle size of below about 3 microns, preferably below about 2 microns. It has been found that attrition resistance is sometimes unsatisfactory when particles much larger than 3 microns are used.

Preferably, both the colloidal oxide sol and the soluble oxide precursor must be chosen so that they have minimum or no deleterious effect on the catalytic performance of the particular catalyst being used. The oxides should be inert or show no catalytic activity for the particular chemical reaction being performed. Further, when an attrition resistant catalyst is being formed by spray during, the resulting peripheral oxide layer should not affect the behavior of the catalytically active phase during the subsequent calcination step and any activation steps. When either or both of these optional components are employed, the morphology of the resulting microspheres should be such that peripheral oxide layer allows the reactants access to the catalytically active phase. And, this oxide-rich surface layer should have no deleterious effect on catalyst performance.

The actual choice of oxide for the colloidal oxide sol can be made independently of the choice of oxide of the soluble oxide precursor provide the above compatibility and performance criteria are met. Preferably the same oxide is to be employed. Thus the oxide is generally any refractory oxide of the appropriate dimensions and compatibility which by way of example but not limitation includes SiO_2 , Al_2O_3 , P_2O_5 , TiO_2 , ZrO_2 , MgO , rare earth oxides, and mixtures thereof. Most preferably, SiO_2 is to be employed.

The SiO_2 colloidal oxide sol can conveniently be any commercially available material, such as those available under the trade names Ludox[®] colloidal silica or Nalco[®] colloidal silica. Typically such commercially available solutions will contain a stabilizing counter ion such as the sodium or

ammonium ion, which is preferably removed prior to use by contact with an acid ion exchange resin. A variety of such silicas with average particle sizes up to several 100 nm have been tested and found satisfactory.

The solvent used in the slurry to be spray dried is a solvent for the oxide precursor. Water is preferred. The solute consists essentially of an oxide precursor of subcolloidal particle size. "Subcolloidal particle size" is defined herein as that of particles for which the largest dimension is no greater than 5 nm. The solute particles must not agglomerate, precipitate or gel during or following the formation of the solution or in contact with the catalyst, catalyst precursor or catalyst support particles. The solute particles must provide a sufficiently stable solution and slurry to permit spray drying. Because the solute particles with the above properties are much smaller than the voids or spaces between the catalyst, catalyst precursor or catalyst support particles, and are even appreciably smaller than the colloid oxide sol particles, when the slurry is spray dried the solute particles can flow with the solvent from the interior to the peripheral region of the porous microsphere formed by the evaporation of the solvent in a droplet of the spray. These solute particles then remain in this peripheral region as the drying is completed and form a hard peripheral shell.

The oxide for this shell can be chosen from the group comprising SiO_2 , Al_2O_3 , P_2O_5 , TiO_2 , ZrO_2 , MgO , and rare earth oxides. Examples of solutes for these oxides are silicic acid, basic aluminum chloride, phosphoric acid, titanyl oxychloride, hydrolyzed zirconyl nitrate, magnesium acetate, and hydrolyzed basic nitrates of rare earths. The preferred oxide is SiO_2 , and the preferred solute or oxide precursor is silicic acid, especially polysilicic acid.

The aqueous silicic acid solution that is useful in this invention contains silica of the proper particle size, i.e., no greater than 5 nm, and provides a solution of sufficient stability to allow the formation of the slurry and subsequent spray drying. The silicic acid can be in the form of a monomer or in the form of low molecular weight polymeric units. It is a very weak acid

and exists only in dilute aqueous solutions. At greater concentrations, the monomer polymerizes to form dimer and higher molecular weight species of silicic acid.

5 The preferred form of silicic acid is polysilicic acid having a concentration expressed as SiO_2 of about 6 wt% for adequate stability. The preferred method of preparation of polysilicic acid is by deionization of an aqueous sodium silicate solution using an ion exchange resin at room temperature. In this way the polysilicic acid solution is substantially free of electrolytes and, therefore, is more stable. Further details and alternatives are
10 described in previously referenced U.S. patents 4,677,084 and 4,769,477.

The slurry which is spray dried is prepared by gradually adding catalyst or catalyst precursor particles to an aqueous mixture of a H_3PO_4 solution, and the colloidal sol and silicic acid solutions. The slurry is stirred until a uniform dispersion is obtained. Preferably the relative amounts of
15 colloidal sol, silicic acid, and catalytic particles are chosen so that the resulting weight of the SiO_2 represents from about 3 to 15 percent of the total weight of the attrition resistant catalyst.

The spray drying and calcining steps can be performed by any of the known processes and equipment generally known in the art. In particular
20 these steps may be performed in a manner similarly to the disclosure in U.S. patents 4,677,084 and 4,769,477.

The following examples are presented to more fully demonstrate and further illustrate various individual aspects and features of the present invention. As such the examples are felt to be non-limiting and are meant to
25 illustrate the invention but are not meant to be limiting in any way.

Example 1

An attrition resistant VPO catalyst having a shell and/or bulk composition of 10% SiO_2 has been prepared.

To (Y grams) of colloidal silica sol (X) having an average particle size
30 (S) with pH (P) was added a strongly acidic sulfonic acid cation exchange resin

(Dowex HCR-W2-H) until the pH was <3.00. The deionized colloid (X) was then separated from the resin by filtration.

A 6.13% by weight sodium silicate solution was prepared by diluting sodium silicate (N Grade; Wesbond Corp.) with distilled water. The pH was
5 lowered to <3.00 by the addition of Dowex HCR-W2-H resin, then stabilized with 6.9% Sulfuric Acid, and the resin was removed by filtration.

The catalyst precursor particles employed were milled hydrogen vanadyl phosphate having a mean particle diameter d50 of (2.0) microns.

A slurry was prepared from (V grams) of the milled VPO precursor
10 particles, (Y grams) of the deionized colloid (X), (Y grams) of the 6.13% by weight PSA solution, (Z Grams) of water, and (F Grams) of 85% Phosphoric Acid (H₃PO₄), by first mixing the aqueous solutions then the VPO precursor particles to form a slurry. The slurry was spray dried on a Bowen Engineering Inc. spray dryer, Model # BE-1425.

15 The conditions for spray drying were:

Inlet temp:	370 ± 5
Outlet temp:	175 ± 5
Atomizer air:	8 psi ± 2
Cyclone ΔP in H ₂ O:	4.5 ± 5
20 Chamber temp:	245 C° ± 5

Calcination and activation was carried out in the following manner: 90g of spray dried VPO/SiO₂ material was loaded into a 4cm diameter fluid bed. The 90g of VPO catalyst was fluidized with air and heated to 390 C° for 1hr. After this calcination step, the VPO catalyst was activated with 1.5%
25 butane at 460 C° for approximately 14hours

Example 2.

An attrition resistant VPO catalyst having a shell and/or bulk composition of 10% SiO₂ has been prepared.

To a mixture of, (Y grams) of colloidal silica sol (X) having an average
30 particle size (S) with pH (P), a 6.13% by weight sodium silicate solution

prepared by diluting sodium silicate (N Grade; Wesbond Corp.) with distilled water, and (F Grams) of 85% Phosphoric Acid (H_3PO_4), was added a strongly acidic sulfonic acid cation exchange resin (Dowex HCR-W2-H) until the pH was <3.00. The deionized mixture was then separated from the resin by
5 filtration.

The catalyst precursor particles employed were milled hydrogen vanadyl phosphate having a mean particle diameter d_{50} of (2.0) microns.

A slurry was prepared from (V grams) of the milled VPO precursor particles, (Y grams) of the deionized colloid (X), (Y grams) of the 6.13% by
10 weight PSA solution, (Z Grams) of water, and (F Grams) of H_3PO_4 , by adding the VPO precursor particles to the aqueous mixture to form a slurry. The slurry was spray dried on a Bowen Engineering Inc. spray dryer, Model # BE-1425.

The conditions for spray drying were:

Inlet temp:	370 ± 5
15 Outlet temp:	175 ± 5
Atomizer air:	$8 \text{ psi} \pm 2$
Cyclone ΔP in H ₂ O:	4.5 ± 5
Chamber temp:	$245 \text{ C}^\circ \pm 5$

Calcination and activation was carried out in the following
20 manner: 90g of spray dried VPO/SiO₂ material was loaded into a 4cm diameter fluid bed. The 90g of VPO catalyst was fluidized with air and heated to 390 C° for 1hr. After this calcination step, the VPO catalyst was activated with 1.5% butane at 460 C° for approximately 14 hours.

25 **Example 3.**

An attrition resistant VPO catalyst having a shell and/or bulk composition of 10% SiO₂ has been prepared.

To (Y grams) of colloidal silica sol (X) having an average particle size (S) with pH (P) was added a strongly acidic sulfonic acid cation exchange resin

(Dowex HCR-W2-H) until the pH was <3.00. The deionized colloid (X) was then separated from the resin by filtration.

The catalyst precursor particles employed were milled hydrogen vanadyl phosphate having a mean particle diameter d50 of (2.0) microns.

5 A slurry was prepared from (V grams) of the milled VPO precursor particles, (Y grams) of the deionized colloid (X), (Z Grams) of water, and (F Grams) of 85% Phosphoric Acid (H_3PO_4), by first mixing the aqueous solutions then the VPO precursor particles to form a slurry. The slurry was spray dried on a Bowen Engineering Inc. spray dryer, Model # BE-1425.

10 The conditions for spray drying were:

Inlet temp:	370 ± 5
Outlet temp:	175 ± 5
Atomizer air:	8 psi ± 2
Cyclone ΔP in H2O:	4.5 ± 5
15 Chamber temp:	245 C° ± 5

Calcination and activation was carried out in the following manner: 90g of spray dried VPO/SiO₂ material was loaded into a 4cm diameter fluid bed. The 90g of VPO catalyst was fluidized with air and heated to 390 C° for 1hr. After this calcination step, the VPO catalyst was activated with 1.5% butane at
20 460 C° for approximately 14 hours.

Example 4.

An attrition resistant VPO catalyst having a shell and/or bulk composition of 10% SiO₂ has been prepared.

25 The catalyst precursor particles employed were milled hydrogen vanadyl phosphate having a mean particle diameter d50 of (2.0) microns.

A slurry was prepared from (V grams) of the milled VPO precursor particles, (Z Grams) of water, and (F Grams) of 85% Phosphoric Acid (H_3PO_4), by first mixing the aqueous solutions then the VPO precursor particles to form a slurry. The slurry was spray dried on a Bowen Engineering Inc. spray dryer,
30 Model # BE-1425.

The conditions for spray drying were:

Inlet temp:	370 ± 5
Outlet temp:	175 ± 5
Atomizer air:	8 psi ± 2
5 Cyclone ΔP in H ₂ O:	4.5 ± 5
Chamber temp:	245 C° ± 5

Calcination and activation was carried out in the following manner: 90g of spray dried VPO/SiO₂ material was loaded into a 4cm diameter fluid bed. The 90g of VPO catalyst was fluidized with air and heated to 390 C° for 1hr. After this calcination step, the VPO catalyst was activated with 1.5% butane at 460 C° for approximately 14 hours.

In A manner analogous to the above Examples, a series of additional runs or partial runs were performed including various selected colloidal sol particle sizes, polysilic acid concentrations and H₃PO₄/H₂SO₄ concentrations. The relevant starting data and results of the respective runs including data are presented in the following Tables.

Oxide Product Name (X)											
PSA	Ludox FM	Ludox SM	Nalco 1115	Nalco 1034A	Nalco 1060	Nalco 2329					
Dry Oxide %											
6.13% SiO2	15% SiO2	30% SiO2	15% SiO2	34% SiO2	50% SiO2	40%	SiO2				
Particle Size (S)											
N/A	50 A	70 A	40 A	200 A	600 A	750 A					
pH (P)											
<3.00	9.7><10.3	10	10.5	2.8	8.5	8.4	VPO	WATE R	H3PO 4	H2SO4	
Run #	Ex.	Oxide weight, g (Y)						g(V)	g(Z)	g(F)	ml (A)
5	1	91.0	704.0					1000.0	982.8	8.4	3.0
6	1	90.7					211.1	1000.0	1476.0	8.4	1.5
7	1	42.9					100.0	1000.0	1556.1	8.2	1.5
8	2	90.0		352.0				1000.0	1407.0	8.7	0.0
9	2	90.0		352.0				1000.0	1407.0	8.7	0.0
10	2	90.0		352.0				1000.0	1407.0	8.7	0.0
11	3						222.2	1000.0	1555.6	8.4	0.0
12	3						277.8	1000.0	1500.0	8.4	0.0
13	3				326.8			1000.0	1451.0	8.4	0.0
14	3			370.4				1000.0	1407.4	8.4	0.0
15	3		740.7					1000.0	1037.1	8.4	0.0
16	3						222.2	1000.0	1555.6	16.8	0.0
17	3			370.4				1000.0	1407.4	16.8	0.0
18	3						222.2	1000.0	1555.6	8.4	0.0
19	3						222.2	1000.0	1555.6	8.4	0.0
20	3						222.2	1000.0	1555.6	8.4	0.0
21	3						222.2	1000.0	1555.6	8.4	0.0
22	3			370.4				1000.0	1407.4	8.4	0.0
23	3			370.4				1000.0	1407.4	8.4	0.0
24	3			370.4				1000.0	1407.4	8.4	0.0
25	3			370.4				1000.0	1407.4	8.4	0.0
26	3						888.9	4000.0	6222.4	67.2	0.0
27	3						105.3	1000.0	1526.3	15.7	0.0
28	3			175.0				1000.0	1524.0	8.2	0.0
29	3			370.4				1000.0	1478.6	8.7	0.0
30	4	0.0	0.0	0.0	0.0	0.0	0.0	1000.0	1500.0	14.7	0.0
31	4	0.0	0.0	0.0	0.0	0.0	0.0	4000.0	6256.0	76.6	0.0

VPO/OXIDE %'S												
Run #	PSA	50 A Ludox FM	70 A Ludox SM	40 A Nalco 1115	200 A Nalco 1034A	600 A Nalco 1060	750 A Nalco 2329	H3PO4 mMol	g/hr Attri.	SA m2/mg	Pore Vol. cc/g	Description
11								50	1.670			10% SiO2/H3PO4
12								50	0.132			10% SiO2/H3PO4
13								50	0.050			10% SiO2/H3PO4
5	5%	95%						50	0.023	31.31	0.13	10% SiO2/H3PO4
14			100%					50				10% SiO2/H3PO4
15		100%						50				10% SiO2/H3PO4
30	0%	0%	0%	0%	0%	0%	0.00	100	0.045	34.80	0.18	100% VPO/H3PO4(No SiO2!!)
16						100%		100	0.018	42.73	0.22	10% SiO2/H3PO4
17			100%					100	0.232			10% SiO2/H3PO4
18						100%		50	0.018			10% SiO2/H3PO4, t=0 hr
19						100%		50				10% SiO2/H3PO4, t=1 hr
20						100%		50				10% SiO2/H3PO4, t=3 hrs
21						100%		50	0.023			10% SiO2/H3PO4, t=5 hrs
22			100%					50	0.008			10% SiO2/H3PO4, t=0 hr
23			100%					50				10% SiO2/H3PO4, t=1 hr
24			100%					50				10% SiO2/H3PO4, t=3 hrs
25			100%					50	0.009			10% SiO2/H3PO4, t=5 hrs
26						100%		100	0.028			10% SiO2 (riser repeat 88545-19)
27						100%		100				5% SiO2/H3PO4
31	0%	0%	0%	0%	0%	0%	0.00	125	0.077	31.41	0.14	100% new VPO (1/4" repet 88545-18)
32	5%		95%					50	0.011			10% SiO2/premix/ H3PO4, t=0 hr
33	5%		95%					50	0.018			10% SiO2/premix/ H3PO4, t=5 hrs
34	5%		95%					50	0.011			10% SiO2/premix/ H3PO4, t=24 hrs
28			100%					50	0.095			5% SiO2/H3PO4
29			100%					50	0.013			10% SiO2/H3PO4
6	5%							50	0.178	32.17	0.15	10% SiO2/H3PO4
7	5%							50	0.053			5% SiO2/H3PO4

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Having thus described and exemplified the invention with a certain degree of particularity, it should be appreciated that the following claims are not to be so limited but are to be afforded a scope commensurate with the wording of each element of the claim and equivalents thereof.

CLAIM

We Claim:

1. Process for manufacture of an attrition resistant
5 vanadium/phosphorous oxide catalyst comprising the steps of:
 - a) forming a slurry comprising;
 - iv) vanadium/phosphorous oxide catalyst or vanadium/
phosphorous oxide catalyst precursor particles,
 - v) aqueous H_3PO_4 solution, and
 - 10 vi) optionally an aqueous colloidal silica sol, an aqueous
polysilicic acid solution or mixture thereof;
 - b) spray drying the slurry from step (a) to form attrition resistant catalyst
precursor solids; and
 - c) calcining the spray dried solids of step (b) to produce attrition
15 resistant catalyst.

ABSTRACT OF THE DISCLOSURE

A method for manufacturing of an attrition resistant vanadium/phosphorous oxide catalyst involving forming an aqueous slurry comprising; vanadium/phosphorous oxide catalyst or vanadium/phosphorous
5 oxide catalyst precursor particles, an aqueous solution of H_3PO_4 , and optionally an aqueous colloidal silica sol, an aqueous polysilicic acid solution or mixture thereof and then spray drying the slurry to form attrition resistant catalyst precursor followed by calcining/activating the spray dried precursor. Such a
10 catalyst is particularly useful in oxidation processes such as the catalytic air oxidation of butane to maleic anhydride.